Application No.	Applicant(s)	
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10/065,302	HENDRICKS, NEIL	Н.
Examiner	Art Unit)
Olivia T Luk	2812	Ar
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ne Examiner.		
re been received. re been received in Application ocuments have been received. re of this communication to file MENT of this application. mitted. Note the attached EX res reason(s) why the oath of the submitted. reson's Patent Drawing Reviews Amendment / Comment of the header according to 37 Cosit of BIOLOGICAL MAT	on No ed in this national stage applicate a reply complying with the research AMINER'S AMENDMENT or Nor declaration is deficient. W (PTO-948) attached or in the Office action of the drawings in the front (not the FR 1.121(d).	quirements NOTICE OF
6. ☐ Interview S Paper No 708), 7. ☐ Examiner's 8. ☑ Examiner's	Summary (PTO-413), ./Mail Date s Amendment/Comment s Statement of Reasons for Allo	
	Examiner Olivia T Luk Dears on the cover sheet was (OR REMAINS) CLOSED of the or other appropriate committed. This application is an and MPEP 1308. The Examiner. The Examiner of this communication to fill the examiner of the examiner of the examiner of the examiner of the header according to 37 Chosit of BIOLOGICAL MATHER OF THE DEPOSIT OF THE DEPOSIT OF BIOLOGICAL MATHER OF THE DEPOSIT OF THE	10/065,302

Application/Control Number: 10/065,302

Art Unit: 2812

DETAILED ACTION

Allowable Subject Matter

- 1. Claims 1-44 are allowed.
- 2. The following is an examiner's statement of reasons for allowance: Prior art of record teach precursor compositions for CVD formation of low k dielectric films comprising an aromatic compound, but fail to teach at least one unsaturated constituent that is ethylenically and/or acetylenically unsaturated. Most precursor compounds are not in gaseous form but solvent form. Prior art of record teach aromatic compounds, but in combination with one of an alkyl, alkoxy, or heterocyclic compound. Lee et al. teach forming precursor compounds to make materials with low dielectric constant with chemical vapor deposition with a polymer comprising an aromatic, but again, wholly fail to teach an unsaturated constituent that is ethylenically and/or acetylenically unsaturated.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

3. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. References not applied are considered state of the art in the area of semiconductor manufacture.

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Olivia T Luk whose telephone number is 571-272-1676. The examiner can normally be reached on 7AM to 4PM Mon-Fri.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, John Niebling can be reached on 571-272-1679. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

OTL

October 29, 2004

John F. Niebling

Supervisory Patent Examiner Technology Center 2800